

ISO

17034:2016

Certificate of Analysis

ISO/IEC

17025:2017

Certified Reference Material

Product ID: MBH-85X PSB3 L

Product Description: Pb/Sb Alloy

Description and Intended Use: This Certified Reference Material is covered under the scope of accreditation to ISO 17034 by LGC Standards - Manchester, NH. As an ISO 17034 certified reference material, appropriate use of this material will fulfill the certified reference material and traceability requirements for use in ISO 17025 accredited laboratories. This CRM may come in the form of a solid disk, or chips. The intended use of this CRM may include, but is not limited to, the calibration of instruments and the validation of analytical methods.

Certified Values listed in wt.% with associated uncertainties

Ag	0.0040	±0.0005	As	0.253	±0.005	Bi	0.023	±0.001	Cd	0.0023	± 0.0004
Cu	0.0316	±0.0008	Ni	0.0018	±0.0002	Sb	2.17	±0.04	Sn	0.144	± 0.006
Te	0.0048	±0.0006	Zn	0.0006	±0.0002						

Indicative Values listed in ppm

Al	(30)	Са	(10)	Fe	(20)	Mg	(100)	Ρ	(10)
Pb	(97%)	S	(90)	Se	(300)	Si	(20)		

Homogeneity and Uncertainty: "Uncertainty" values, as reported adjacent to certified concentration values, are based on a 95% Confidence Interval. These estimated uncertainties include the combined effects of method imprecision, material inhomogeneity, and any bias between methods. Homogeneity data from experimental XRF results are reflected in both the overall statistics and certified data. Homogeneity samples are selected by a systematic sampling procedure. The number of samples may be determined by equation 1, where Nprod is the number of units produced and Nmin is the number of samples used for homogeneity testing. These samples are arranged in a simple randomized design such that each sample is analyzed multiple times by XRF. Homogeneity may also be determined within sample using an applied version of ASTM E826. A single factor ANOVA is used to calculated uncertainty due to inhomogeneity (Uhom). Uncertainty of the material is calculated by equation 2, where H=U_{hom}, S= Standard deviation, t= t-value at 95% CI, and n= number of observations.

$$1.N_{MIN} = \max(10, \sqrt[3]{N_{PROD}})$$

$$2. U_{CRM} = \frac{\sqrt{H^2 + S^2}}{\sqrt{n}} * t$$

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Universal Scientific Laboratory - Revesby NSW, Australia

EAG Laboratories - Liverpool, NY

Instytut Metali Niezelaznych - Gliwice, Poland

Certification Laboratories: Much of the analytical work performed to assess this material has been carried out by laboratories with proven competence, as indicated by their accreditation to ISO 17025. It is an implicit requirement for this accreditation that analytical work should be performed with due traceability, via an unbroken chain of comparisons, each with stated uncertainty, to primary standards such as the mole, or to nationally- or internationally-recognised reference materials. Of the individual results herein, some have traceability (to the mole) via primary analytical methods. Some are traceable to substances of known stoichiometry. Most have traceability via commercial solutions. Furthermore, some results have additional traceability to NIST standards, as part of the analytical calibration or process control.

- . LGC Standards - Manchester, NH
- Alpha Assembly Solutions Altoona, PA
- Connecticut Metallurgical, Inc. East Hartford, CT Dirats Laboratories - Westfield, MA
- Inppamet Anodos Calama, Chile IMR Test Labs - Lansing, NY

- SGS MSi Melrose Park, IL
- TEC-Eurolab Campogalliano, Italy
- NSL Analytical Services Cleveland, OH
- Scrooby's Laboratory Services Benoni, South Africa
- Instructions for Use: The test surface is on the opposite side of the labeled surface, which includes the material identification. This material is individually chill cast per piece. This manner of casting can cause the formation of inhomogeneous segregates in the upper, engraved portion of the disk. Therefore, the certification information above is not applicable to within 3mm of the engraved surface. Each packaged disk has been prepared by finishing the test surface using a lathe. The user must determine the correct surface preparation procedure for each analytical technique. The user is cautioned to use care when either resurfacing the disk or performing additional polishing, as these processes may contaminate the surface. The minimum sample size for chips should be individually evaluated based on the analytical technique used; this would typically be greater than 0.1 grams. The material should be stored in a cool, dry location when not in use. Chips are not recommended for gas analysis.

Period of Validity: The certification of this material is valid indefinitely, within the uncertainty specified, provided the material is handled and stored in accordance with the instructions stated on this certificate. The certification is nullified if the material is damaged, contaminated, otherwise modified, or used in a manner for which it was not intended.

huck Lordren

Chuck Goudreau, Certifying Officer

26 May 2022 **Certification Date**



ISO 17034 Accredited: Reference Materials Producer, Certificate # 2848.02 ISO/IEC 17025 Accredited: Chemical Testing, Certificate # 2848 01

Conditions of Sale and Supply: All CRMs & RMs sold are subject to applicable LGC Standard Terms and Conditions of Sale. Page 1 of 2



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9001:2015



The following data represents all pertinent information reported as it applies to the chemical characterization of this material.

	Ag	Al	As	Bi	Ca	Cd	Cu	Fe	Mg	Ni	Р	Pb	S
1	0.0029	0.0030	0.2380	0.0186	0.0001	0.0016	0.0290	0.0003	0.0001	0.0013	0.0010	97.340	0.0046
2	0.0030	<0.001	0.2440	0.0200	0.0001	0.0019	0.0300	0.0040	0.0010	0.0015		97.490	0.0060
3	0.0034		0.2470	0.0200	0.0005	0.0019	0.0300	< 0.001	0.0207	0.0015			0.0071
4	0.0035		0.2480	0.0214	0.0010	0.0019	0.0301		< 0.00005	0.0017			0.0077
5	0.0038		0.2490	0.0217	0.0020	0.0020	0.0307		<0.0001	0.0017			0.0092
6	0.0038		0.2496	0.0228	< 0.0005	0.0021	0.0309		<0.0005	0.0018			0.0098
7	0.0040		0.2512	0.0229	< 0.0005	0.0021	0.0313		<0.001	0.0018			0.0121
8	0.0040		0.2540	0.0231	<0.001	0.0022	0.0313		<0.001	0.0019			0.0130
9	0.0040		0.2550	0.0235	<0.005	0.0029	0.0314		<0.0010	0.0020			0.0138
10	0.0041		0.2580	0.0235	<0.0050	0.0030	0.0320		<0.005	0.0020			< 0.0005
11	0.0048		0.2590	0.0239		0.0030	0.0331			0.0021			< 0.0100
12	0.0050		0.2608	0.0240		0.0030	0.0333			< 0.001			
13	0.0052		0.2640	0.0257		< 0.002	0.0334			<0.0010			
14	< 0.005		0.2674	0.0259			0.0334			<0.005			
15							0.0338						
16													
Mean	0.0040	0.0030	0.2532	0.0226	0.0007	0.0023	0.0316	0.0022	0.0073	0.0018	0.0010	97.415	0.0092
STDV	0.0007		0.0081	0.0021	0.0008	0.0005	0.0015	0.0026	0.0116	0.0002		0.1061	0.0032
Certified	0.0040	(0.003)	0.253	0.023	(0.001)	0.0023	0.0316	(0.002)	(0.01)	0.0018	(0.001)	(97.0)	(0.009)
UCRM	0.0005		0.005	0.001		0.0004	0.0008			0.0002			
Methods	O,I,IM,A,X	1	O,I,A,X,IM	O,I,IM,A,X	I,IM,O	O,I,IM,A,X	O,I,IM,A,X	0,1	I,IM,X	O,I,IM,A			O,I,C,A,X

	Sb	Se	Si	Sn	Te	Zn
1	1.9560	0.0026	0.0020	0.1160	0.0033	0.0002
2	2.0700	0.0035		0.1307	0.0040	0.0004
3	2.1000	0.0110		0.1320	0.0041	0.0004
4	2.1259	0.0200		0.1350	0.0043	0.0006
5	2.1260	0.0227		0.1401	0.0043	0.0008
6	2.1330	0.0240		0.1410	0.0045	0.0008
7	2.1600	0.0244		0.1442	0.0046	0.0010
8	2.1700	0.0300		0.1480	0.0050	< 0.001
9	2.1820	0.0370		0.1490	0.0051	<0.0010
10	2.1930	0.0388		0.1491	0.0051	<0.0010
11	2.2000	0.0420		0.1500	0.0054	< 0.002
12	2.2070	0.0455		0.1520	0.0057	< 0.002
13	2.2097	<0.0050		0.1524	0.0070	< 0.005
14	2.2280			0.1540	< 0.005	
15	2.2670			0.1540		
16	2.3200			0.1620		
Mean	2.1655	0.0251	0.0020	0.1443	0.0048	0.0006
STDV	0.0839	0.0143		0.0115	0.0009	0.0003
Certified	2.17	(0.03)	(0.002)	0.144	0.0048	0.0006
UCRM	0.04			0.006	0.0006	0.0002
Methods	X,I,A,O	I,IM,O	1	O,I,A,X	O,IM,I,A,X	I,IM,A,X,O

Legend: W = Classical, C = Combustion, F = Fusion, A = AA or GFAA, I = ICP or DCP, IM=ICP-MS, D = DC Arc, O = AES, X = XRF, G = GDAES or GDMS, H = Hollow Cathode AES

